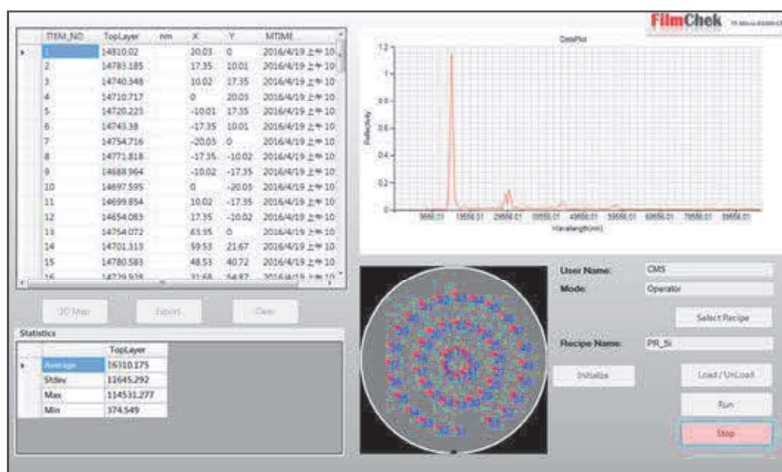


Film Thickness Measurement System

Fulfill all your needs with limited budget

- ◆ Spot size : Φ 50 μ m (option to 80 μ m, 120 μ m, 250 μ m , 1.2 mm)
- ◆ Thickness range : 1 nm-30 μ m (option to 80 μ m)
- ◆ Thickness Repeatability : <1 nm @ 500 nm Oxide on Si substrate
- ◆ Wafer size : 4~12 inch(R- Θ stage)
- ◆ Vacuum Chuck and color preview camera
- ◆ Built-in Template (n, k) and Multi-layer Model Setup



#filmthickness, wafer thickness, TSV

